# QOCVO

### **TGA2238** 8 – 11 GHz 60 W GaN Power Amplifier

#### **Product Overview**

Qorvo's TGA2238 is a high power MMIC amplifier fabricated on Qorvo's production 0.25 $\mu$  GaN on SiC process (QGaN25). The TGA2238 operates from 8 – 11 GHz and provides a superior combination of power, gain and efficiency by achieving more than 60 W of saturated output power with 25 dB of large signal gain and more than 42% power-added efficiency.

This superior performance provides system designers the flexibility to improve system performance while reducing size and cost.

The TGA2238 is matched to  $50\Omega$  with integrated DC blocking capacitor on RF input port simplifying system integration. It is ideally suited for military and commercial x-band radar systems.

Lead-free and RoHS compliant.

Functional Block Diagram

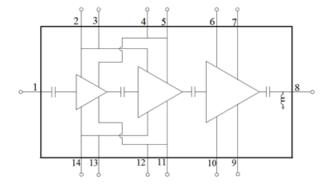


#### **Key Features**

- Frequency Range: 8 11 GHz
- POUT: 48 dBm (PIN = 23 dBm)
- PAE: 42% (P<sub>IN</sub> = 23 dBm)
- Large Signal Gain: 25 dB
- Small Signal Gain: 31 dB
- Return Loss: >10 dB
- Bias: V<sub>D</sub> = 28 V, I<sub>DQ</sub> = 650 mA
- Chip Dimensions: 5.49 x 7.00 x 0.10 mm

#### **Applications**

• X-band radar



#### **Ordering Information**

Part No.	Description
TGA2238	8 – 11 GHz 60 W GaN Power Amplifier
TGA2238EVBP01	TGA2238 Evaluation Board



#### **Absolute Maximum Ratings**

Parameter	Rating
Drain Voltage (V <sub>D</sub> )	40 V
Gate Voltage Range (V <sub>G</sub> )	–8 to 0 V
Drain Current (I <sub>D</sub> )	8 A
Gate Current (I <sub>G</sub> )	See plot on page 7
Power Dissipation ( $P_{DISS}$ ), 85°C, PW = 100us; DC = 10%	158 W
Input Power (P <sub>IN</sub> ) 50 $\Omega$ :, V <sub>D</sub> =25 V, 85 °C, Pulsed: PW = 100 us; DC = 10%	30 dBm
Input Power (P <sub>IN</sub> ), VSWR 3:1: V <sub>D</sub> =25 V, 85 °C, PW = 100 us; DC = 10%	30 dBm
Mounting Temperature (30 seconds)	320 °C
Storage Temperature	–55 to 150 °C

Exceeding any one or a combination of the Absolute Maximum Rating conditions may cause permanent damage to the device. Extended application of Absolute Maximum Rating conditions to the device may reduce device reliability.

#### **Recommended Operating Conditions**

Parameter	Тур.	Units
Drain Voltage (V <sub>D</sub> )	28 V	V
Drain Current, Quiescent (I <sub>DQ</sub> )	650 mA	mA
Operating Temperature Range	-40 to 85	°C

Electrical specifications are measured at specified test conditions. Specifications are not guaranteed over all recommended operating conditions.

#### **Electrical Specifications**

Parameter	Min	Тур	Max	Units
Operational Frequency Range	8		11	GHz
Output Power (Pin = 23 dBm)		48		dBm
Power Added Efficiency (Pin = 23 dBm)		42		%
Power Gain (Pin = 23 dBm)		25		dB
Power @ 1dB Compression (P1dB)		36		dBm
Small Signal Gain		31		dB
Input Return Loss		15		dB
Output Return Loss		15		dB
Small Signal Gain Temperature Coefficient		-0.058		dB/°C
Output Power Temperature Coefficient		-0.014		dBm/°C

Test conditions unless otherwise noted: 25 °C ,  $V_D = 28 \text{ V}$ ,  $I_{DQ} = 650 \text{ mA}$ , PW = 100 us, DC = 10%

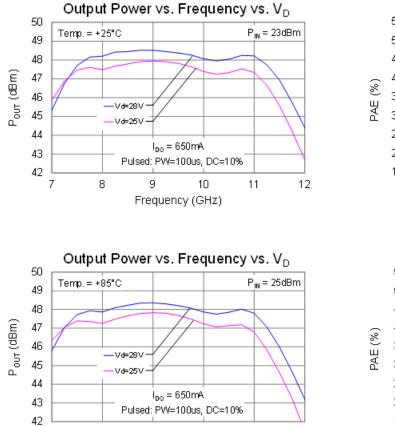
## QONOD

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#### Performance Plots – Large Signal (Pulsed)

Test conditions unless otherwise noted: 25 °C ,  $V_D = 28 \text{ V}$ ,  $I_{DQ} = 650 \text{ mA}$ ,  $P_{IN} = 23 \text{ dBm}$ , PW = 100 us, DC = 10%

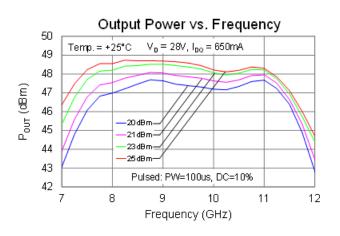


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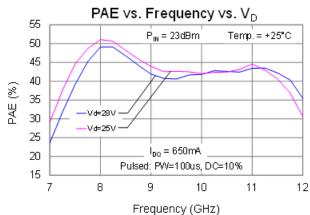
Frequency (GHz)

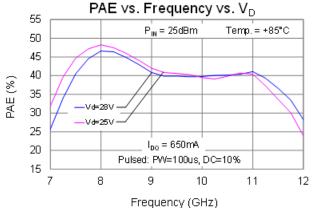
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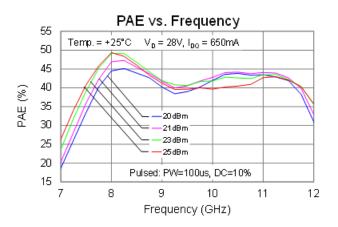
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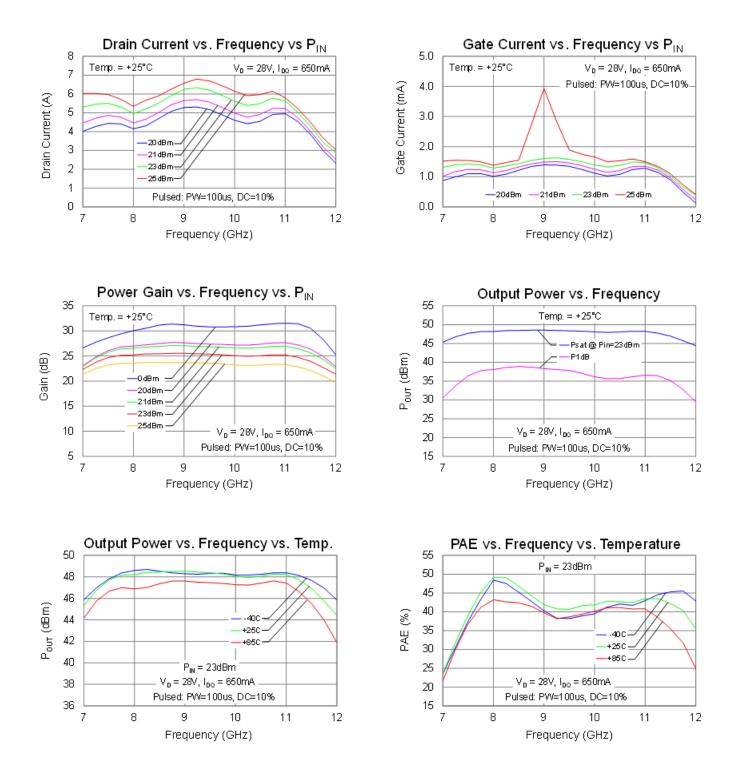




## QONOD

#### Performance Plots – Large Signal (Pulsed)

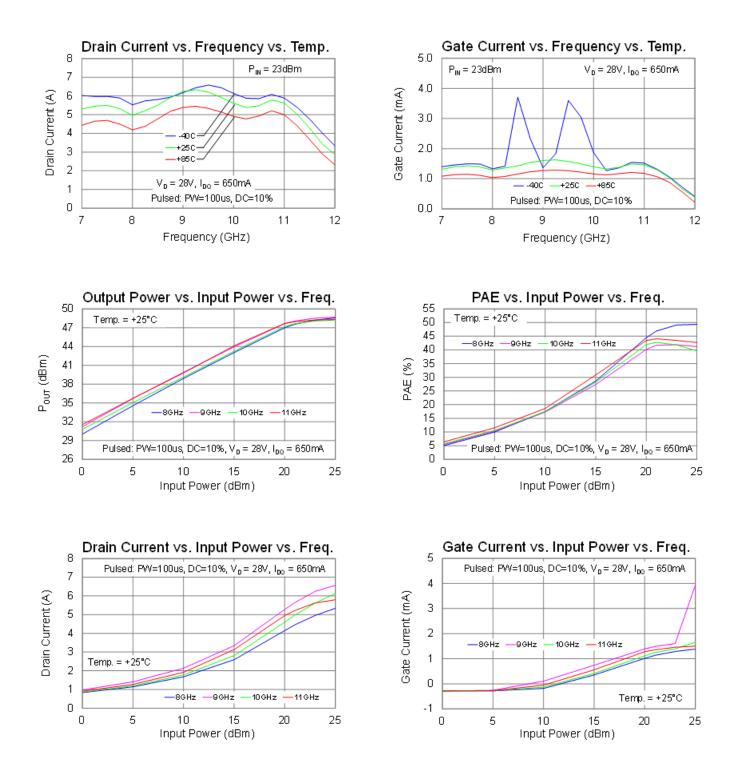
Test conditions unless otherwise noted: 25 °C , V<sub>D</sub> = 28 V, I<sub>DQ</sub> = 650 mA, P<sub>IN</sub> = 23 dBm, PW = 100 us, DC = 10%



## QONOD

#### Performance Plots – Large Signal (Pulsed)

Test conditions unless otherwise noted: 25 °C ,  $V_D = 28 \text{ V}$ ,  $I_{DQ} = 650 \text{ mA}$ ,  $P_{IN} = 23 \text{ dBm}$ , PW = 100 us, DC = 10%

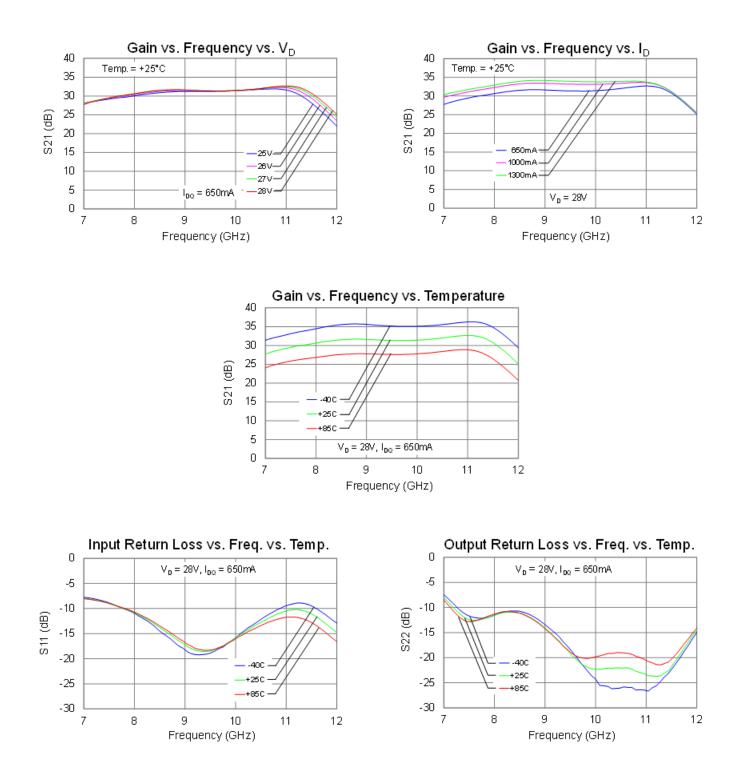


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#### TGA2238 8 – 11 GHz 60 W GaN Power Amplifier

#### Performance Plots – Small Signal

Test conditions unless otherwise noted: 25 °C ,  $V_D$  = 28 V,  $I_{DQ}$  = 650 mA, CW





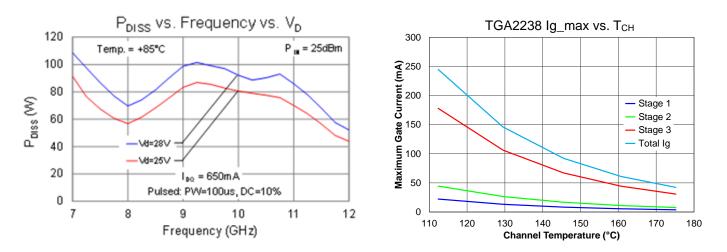
#### **Thermal and Reliability Information**

Parameter	Test Conditions	Value	Units
Thermal Resistance ( $\theta_{JC}$ ) <sup>(1)</sup>	T <sub>base</sub> = 85 °C, PW = 100 us, DC = 10%, V <sub>D</sub> = 25 V, I <sub>D_Drive</sub> = 6 A, Freq = 9.25 GHz, P <sub>IN</sub> =25 dBm,	0.57	°C/W
Channel Temperature (T <sub>CH</sub> ) (Quiescent) $^{(2)}$	$P_{OUT} = 47.8 \text{ dBm}, P_{DISS} = 92 \text{ W}$	137	°C
Thermal Resistance (θ <sub>JC</sub> ) <sup>(1)</sup>	$T_{base} = 85 \text{ °C}, PW = 100 \text{ us}, DC = 10\%, V_D = 28 \text{ V},$	0.58	°C/W
Channel Temperature (T <sub>CH</sub> ) (RF Drive) <sup>(2)</sup>	$I_{D_Drive} = 6.3 \text{ A}, \text{ Freq} = 9.25 \text{ GHz}, P_{IN} = 25 \text{ dBm}, P_{OUT} = 48.3 \text{ dBm}, P_{DISS} = 107 \text{ W}$	147	°C

Notes:

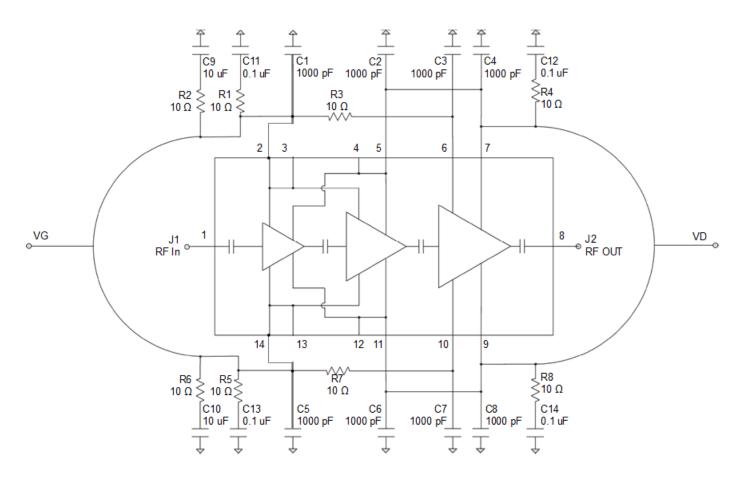
- 1. Thermal resistance determined to the back of a 20 mil Cu-Mo carrier plate with eutectic die attach (85 °C)
- 2. IR Scan equivalent channel temperature. Refer to the following document: <u>GaN Device Channel Temperature, Thermal</u> <u>Resistance, and Reliability Estimates</u>

#### **Power Dissipation and Maximum Gate Current**





#### **Applications Information**



#### Notes:

1.  $V_G \& V_D$  need to be biased from both sides.

#### **Bias-Up Procedure**

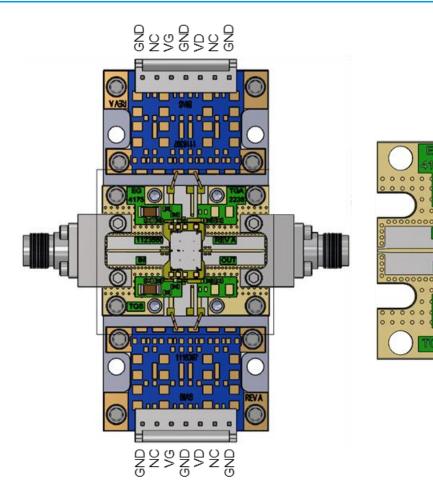
- 1. Set I<sub>D</sub> limit to 8000 mA, I<sub>G</sub> limit to 20 mA
- 2. Set V<sub>G</sub> to -5.0 V
- 4. Set V<sub>D</sub> +28 V
- 5. Adjust  $V_G$  more positive until  $I_{DQ}\approx 650~mA$
- 6. Apply RF signal

#### **Bias-Down Procedure**

- 1. Turn off RF signal
- 2. Reduce  $V_G$  to –5.0 V. Ensure  $I_{DQ} \sim 0 \mbox{ mA}$
- 4. Set  $V_{\text{D}}$  to 0 V
- 5. Turn off  $V_{\mathsf{D}}$  supply
- 6. Turn off V<sub>G</sub> supply



#### **Evaluation Board (EVB) Layout Assembly**

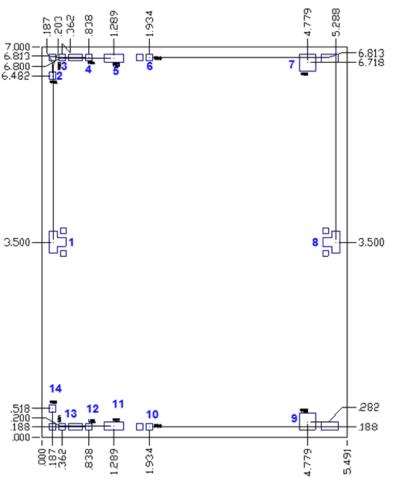


#### **Bill of Materials**

Reference Des. Value		Description	Manuf.	Part Number	
C1 – C8	1000 pF	Cap, 1000 pF, 10%, 50V, BORDER, SL	Various	Various	
C9 – C10	0.1 uF Cap, 10 uF, 20%, 50V, X5R, 1206		Various	Various	
C11 – C14	10 uF Cap, 0.1 uF, 10%, 50V, X7R, 0402		Various	Various	
R1 – R8	10 Ω	Res, 10 Ohm, 5%, 0.1 W, 0402	Various	Various	
J1, J2	2.92 mm	RF Connector, 2.92 mm (F)	Southwest Microwave	1092-01A-5	



#### **Mechanical Information and Bond Pad Description**



Units: millimeters Thickness: 0.100Die x,y size tolerance:  $\pm 0.050$ Chip edge to bond pad dimensions are shown to center of pad Ground is backside of die

#### **Bond Pad Description**

Pad No.	Symbol	Pad Size (mm)	Description
1	RF Input	0.146 x 0.386	RF Input; matched to $50\Omega$ ; DC blocked
2, 14	VG1	0.121 x 0.121	VG1 and VG2 are internally connected so either one can be used for both
3, 13	VG2	0.121 x 0.121	VG1 or VG2, bias network is required; see Application Circuit on page 8 as an example.
4, 12	VD1	0.121 x 0.121	VD1 and VD2 are internally connected so either one can be used for both
5, 11	VD2	0.346 x 0.146	VD1 or VD2, bias network is required; see Application Circuit on page 8 as an example.
6, 10	VG3	0.121 x 0.121	VG3, bias network is required; see Application Circuit on page 8 as an example.
7, 9	VD3	0.296 x 0.310	VD 3, bias network is required; see Application Circuit on page 8 as an example.
8	RF Output	0.146 x 0.386	RF Output; matched to $50\Omega$ ; DC shorted to ground



#### **Assembly Notes**

Component placement and die attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Conductive epoxy attachment may be used for small-signal low power dissipation die.
- Follow manufacture instructions for epoxy curing.

Reflow process assembly notes:

- Use AuSn (80/20) solder and limit exposure to temperatures above 300°C to 3-4 minutes, maximum.
- An alloy station or conveyor furnace with reducing atmosphere should be used.
- Do not use any kind of flux.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonic are critical parameters.
- Aluminum wire should not be used.
- Devices with small pad sizes should be bonded with 0.0007-inch wire.